

HATHE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Jong Jin PARK et al.

Application No.: 10/814,264

Filed: April 1, 2004

For: PHOTOSENSITIVE SEMICONDUCTOR

NANOCRYSTALS, PHOTOSENSITIVE

COMPOSITION COMPRISING

SEMICONDUCTOR NANOCRYSTALS

AND METHOD FOR FORMING

SEMICONDUCTOR NANOCRYSTAL

PATTERN USING THE SAME

Group Art Unit: 2826

Examiner: THOMAS L. DICKEY

Confirmation No.: 8445

AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Official Action of December 2, 2005, please amend the above-identified Application as indicated.